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PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

re the application of: Seung Chul HA, et al.

Serial No.: 10/788,441 Group Art Unit: 2855

Filed: March 1, 2004 Examiner: Cygan, Michael T

For: SENSOR AND METHOD FOR MANUFACTURING THE SAME

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RESPONSE TO ELECTION/RESTRICTION REQUIREMENT

Mail Stop Amendment
P.O. Box 1450
Alexandria, VA 22313-1450

June 14, 2005

Sir:

In response to the Request for Election/Restriction mailed May 16, 2005, Applicant elects Group I, claims 1-8, drawn to a sensor, classified in class 73, subclass 31.06, with traverse.

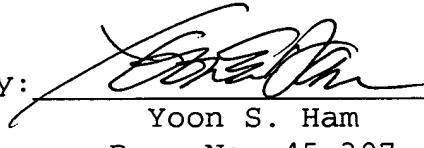
Applicant respectfully traverses the election/restriction requirement. The claims of Group II (Claims 9-13) drawn to a method for removing material from a substrate to form a sensor, and the claims of Group I (Claims 1-8) drawn to a sensor are closely related to each other and define a single invention. The sensor defined in claims 1-8 is manufactured by the process of claims 9-13, and thus, claims 1-13 define a single inventive concept. Further, Applicant respectfully submits that it would not be unduly burdensome for the Examiner to examine the claims of both groups. Applicant respectfully requests that claims 1-3 be examined.

An early Office Action on the merits is respectfully requested.

If a Petition for Extension is necessary and the petition and/or check is not enclosed, this will act as a petition to extend the time for response and authorization to charge the necessary fees under 37 CFR 1.17(a)-(d) to Deposit Account **503-121**.

Respectfully submitted,
MAYER BROWN ROWE & MAW LLP

By:


Yoon S. Ham
Reg. No. 45,307
Direct Tel.: (202) 263-3280

MAYER BROWN ROWE & MAW LLP
1909 K Street, NW
Washington, DC 20006-1101

Atty. Dkt.: **123034-05004806**
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